

Image



03500.010530.5

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
KIYOFUMI SAKAGUCHI, ET AL.)	Examiner: G. Fourson, III
Appln. No.: 10/085,046)	Group Art Unit: 2823
Filed: March 1, 2002)	
For: PROCESS FOR PRODUCTION OF SEMICONDUCTOR SUBSTRATE)	
	:	October 21, 2003

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SECOND INFORMATION DISCLOSURE STATEMENT

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO-1449. Copies of the listed documents are also enclosed.

REMARKS

Applicants respectfully note that Japanese Laid-Open Patent Application No. 5-217827 ("JP '827") was cited in the examination of Japanese Patent Application No. 7-45441, a priority application of the subject application. Applicants respectfully submit that EP 0 553 859, which was cited in the September 6, 2002, Information Disclosure Statement, corresponds to JP '827.

Applicants respectfully submit that Japanese Laid-Open Patent Application No. 5-217981 ("JP '981") discloses, e.g., that after H₂ annealing a porous layer, epitaxial growing is carried out. Applicants respectfully submit that EP 0 553 861 corresponds to JP '981.

Abstracts for each Japanese document are also enclosed.

FORMAL MATTERS

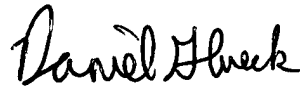
No fee is believed due; however, any fee required in connection with this paper should be charged to Deposit Account 06-1205. A duplicate of this paper is enclosed.

CONCLUSION

It is respectfully requested that the above information be considered by the Examiner and that a copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should continue to be directed to our address given below.

Respectfully submitted,

A handwritten signature in black ink, reading "Daniel Glueck". The signature is fluid and cursive, with the first name "Daniel" and last name "Glueck" clearly distinguishable.

Attorney for Applicants
Daniel S. Glueck
Registration No. 37,838

FITZPATRICK, CELLA, HARPER & SCINTO
30 Rockefeller Plaza
New York, New York 10112-3800
Facsimile: (212) 218-2200

DSG/dc
DC_MAIN 147598 v 1

FORM PTO 1449 (modified) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S) (Use several sheets if necessary) Submitted: October 21, 2003			ATTY DOCKET NO. 03500.0105305		APPLICATION NO. 10/085,046	
			APPLICANT KIYOFUMI SAKAGUCHI, ET AL.			
			FILING DATE March 1, 2002		GROUP 2823	

U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	

FOREIGN PATENT DOCUMENTS							
DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT		
5-217981	8/27/93	Japan			Abstract		
5-217827	8/27/93	Japan			Abstract		
0 553 861 A1	8/04/93	Europe					

OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)		

EXAMINER	DATE CONSIDERED
----------	-----------------

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Sheet 1 of 1